Temperature dependent dynamic and static magnetic response in magnetic tunnel junctions with Permalloy layers

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Since the discovery of large room temperature magnetoresistance in magnetic tunnel junctions (MTJs) there have been continuous efforts to improve the quality of MTJs and optimize their dynamic response, important for different applications. In order to optimize the low field performance, the MTJ sensors employ magnetically soft ferromagnetic (FM) films typically made of Permalloy (Py) (Ni$_{80}$Fe$_{20}$). Knowledge of the dynamic and static magnetic response of Py in a wide temperature range is therefore crucial in a view of potential low temperature applications of these spintronic devices. It was observed in the late 1960s that the temperature dependence of the FM resonance (FMR) for in-plane magnetized single Py films shows anomalous variation of the FMR linewidth which has been attributed to spin-impurity interaction enhanced damping. More recently, enhancement of the FMR frequency in single Py films with decreasing temperature has been observed and explained in terms of spin reorientation transition at the Py interface below 100 K. This letter presents an investigation of the temperature dependence of the FM resonance excited in the Py layers in magnetic tunnel junctions shows “kneelike” enhancement of the resonance frequency accompanied by an anomaly in the magnetization near 60 K. We attribute the anomalous static and dynamic magnetic response at low temperatures to interface stress induced magnetic reorientation transition at the Py interface which could be influenced by dipolar soft-hard layer coupling through the Al$_2$O$_3$ barrier. © 2008 American Institute of Physics. [DOI: 10.1063/1.3005644]

The free FM electrodes were Co$_{90}$Fe$_{20}$B$_{20}$ (2 nm)/Ni$_{80}$Fe$_{20}$ (23 nm) for sample B and Co$_{90}$Fe$_{10}$ (3nm)/Ni$_{80}$Fe$_{20}$ (28 nm) for sample C. The entire wafers were covered with a Ta (5 nm)/Cu (5 nm) layers to prevent oxidation and were annealed at 250 °C in the sputtering chamber during 1 h in an in-plane applied magnetic field of 20 mT. For more details on sample growth and characterization, see Refs. 8 and 9.

The low temperature FMR experiments were carried out with a Vector Network Analyzer (VNA) working up to 8.5 GHz by employing VNA-FMR technique which uses a coplanar wave guide to create the pumping field $h_{rf}$ and a variable temperature cryostat with a rf insert. In order to determine the dynamic response of the free-FM layer, an in-plane external bias field $H_{ap}$ was applied along the easy axis with $h_{rf}$ being transverse to $H_{ap}$. The data analysis is described in more details in Ref. 10. A superconducting quantum interference device magnetometer was used to measure the field dependence of the in-plane magnetization $M$. In addition, the structures of the different layers and interfaces were investigated at room temperature by transmission electron microscopy (TEM) in high resolution mode.

Figure 1 shows the loss profile (see Ref. 10) of the FMR frequency measured at 150 K and at 10 K for the three samples investigated. In order to describe in more detail the temperature dependence of FMR, Fig. 2 compares $f_0(T)$ and $\Delta f_0(T)$ for samples A–C determined with field $\mu_0H_{ap}$ = 20 mT. Both MTJ samples (B and C) show independent of the magnetic field history an increase in the FMR frequency below a temperature $T_R$ of about 65 K, with the increase being more pronounced for the MTJ-C (see also Fig. 1). These changes in the FMR are accompanied by nearly step-like changes in the FMR linewidth below $T_R$. The single Py film (sample A), however, shows a more gradual enhancement of the FMR frequency and the linewidth below roughly 100 K, which is in a good agreement with previous studies.

The presence of a weak step-like increase in the...
FMR linewidth just below 55 K in sample A can also be observed in Fig. 2(b).

Figure 3(a) illustrates quasistatic magnetization curves for the MTJ-C measured for temperatures close to 60 K. Here we shall focus on the field intervals where both free-FM and pinned-FM layers are forced to the mostly parallel alignment (AP) and on the region of the antiparallel alignment (AP). By analyzing the low field hysteresis loops of the free-FM layer near P = > AP transition we determine the switching field of the free-FM layer as a function of temperature [Fig. 3(b)]. One clearly sees that in both types of the MTJs the switching field is substantially lower than observed in the single Py film. This difference may indicate the presence of dipolar fields induced interaction between hard and soft layers in MTJs which influences domain wall nucleation and propagation in the soft layer.

For all samples the high field magnetization curves M(H) in the P state show magnetization saturation above few 0.2 T, except in the proximity to 55–70 K where some deviation from the saturation behavior with an anomalous peak and dip in the M(H) dependence below and above a critical temperature is observed. Data for the MTJ-C, where this unusual behavior in M(T,H) in the P-state is mostly remarkable, with up to 20% deviation in the high field magnetization, is shown in Fig. 3(a). In order to compare M(H,T) dependences for samples A–C, Fig. 3(b) shows the temperature dependence of the high field magnetization in the applied field of 0.5 T (further M_s) normalized by the corresponding M_s (5 K) values. For all samples M_s(T) is close to one, except in proximity to the temperature interval around 55–70 K where an anomaly is observed. One clearly sees that this anomaly is strongest and shows qualitatively different temperature dependence with peak and dip close to 60 K for the MTJ B and C in comparison with the single Py film (A) where only weak maximum (about 3% deviation) is seen [see inset of Fig. 3(c)] which may reflect transition from perpendicularly oriented Py interface spins at T<T_R to in-plane disordered Py interface spins at T>T_R.

We believe that the high field magnetization anomaly is evidence of a magnetic RT roughly below T_R≈60 K in the magnetically soft layer. To show this more clearly, we marked with arrows the positions of the corresponding anomalies in M_s(T) in Fig. 2(a). The differences in the temperature dependence of FMR and magnetization in MTJ-B, C compared to single Py film (A), may indicate some fundamental changes in the RT occurring in the soft layer, most probably related to the presence of magnetically hard layer.

In order to understand these differences which include the anomalous behavior in the M_s(T) close to T_R accompanied by clear “kneelike” variation of the FMR frequency in
MTJs B and C, we propose a simple model (see sketch in Fig. 4) which considers the mutual influence of the pinned (hard) layer and the free (soft) one, induced by dipolar antiferromagnetic coupling through the Al₂O₃ barrier with some anticorrelated roughness. Figure 4(a) sketches magnetization in the region of the soft and hard layers interfacing Al₂O₃ barrier at temperatures \( T \ll T_R \) when the MTJ stack is situated in 0.5 T field. These layers may have magnetic moments directed mostly out of plane due to the surface anisotropy in the Py and dipolar coupling. This means that both interface magnetic moments tend to occupy a relative minimum of the energy corresponding to an out-of-plane magnetization configuration, reducing therefore the total in-plane magnetization energy minimum. Figure 4(b) schematically shows what may happen at \( T \ll T_R \). When the hard layer, due to its coupling to the soft layer and due to the strong difference in the soft and hard layer metastable energy profiles, is pushed toward in-plane (trending to be antiparallel to the soft layer) magnetization configuration, reducing therefore the total in-plane magnetization \( M_s^\parallel(T) \). Finally, at \( T \geq T_R \) both soft and hard layers turn to have in-plane magnetization (both balls in the sketch in Fig. 4(d) occupy their absolute minima of energy) in equilibrium conditions with an AP alignment showing a total magnetization of the stack nearly the same as at \( T \rightarrow 0 \). Within our model, the quantitative differences between response observed in MTJ B and C could be attributed to different materials interfacing the Py layer (CoFe or CoFeB) which could determine the stress at the Py interface.

**In conclusion**, temperature dependent dynamic and static magnetic response in MTJs with Py layers shows a magnetic reorientation transition below 60 K which is qualitatively different from one reported for single Py films, most probably due to dipolar soft-hard layer coupling. These findings could be important for low temperature applications of devices incorporating Py.

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